



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 21, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

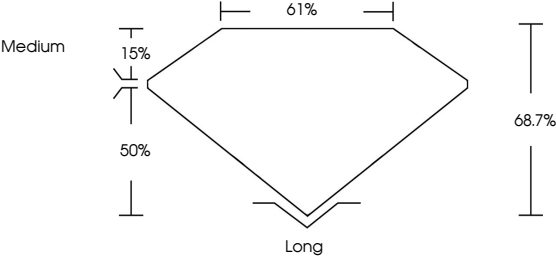
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

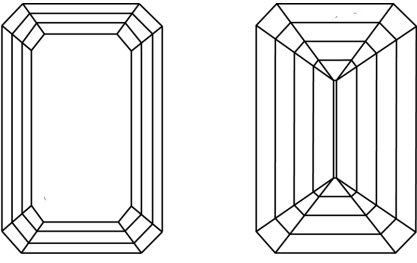
LG830652160

Report verification at [igi.org](https://www.igi.org)

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

Sample Image Used

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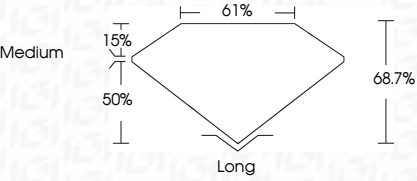
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IGI



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IGI Report No LG830652160

EMERALD CUT

3.86 CARATS

E

VVS 2

68.7%

61%

Medium

Long

EXCELLENT

EXCELLENT

NONE

IGI LG830652160

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10.25 X 7.55 X 5.19 MM

Color Grade

Clarity Grade

Depth

Table

Graile

Culet

Polish

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Fluorescence

Inscription(s)

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